



IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

Applicant: Cyril Cabral, Jr., et al. **Docket:** Y0R920030218US1 (16714)

Serial No: 10/662,900 **Date:** July 26, 2004

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For: REDUCTION OF SILICIDE FORMATION TEMPERATURE ON SiGe CONTAINING SUBSTRATES

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

REQUEST FOR CHANGE OF MAILING ADDRESS

Sir:

Applicant(s) request(s) that all future correspondence in connection with this application be directed and addressed to:

STEVEN FISCHMAN, ESQ.
SCULLY, SCOTT, MURPHY AND PRESSER
Correspondence Address Customer No. 23389
Direct all telephone calls to: (516) 742-4343.

Respectfully submitted:


Robert M. Trepp
Registration No. 25,933

SCULLY, SCOTT, MURPHY & PRESSER
400 Garden City Plaza
Garden City, New York 11530
(516) 742-4343